

AMENDMENTS TO THE CLAIMS:

This listing of claims will replace all prior versions, and listings, of claims in the application:

LISTING OF CLAIMS:

1-70. (canceled)

71. (currently amended) A semiconductor device having a semiconductor multi-layer structure which includes at least one active layer including at least one luminescent layer of $\text{In}_x\text{Al}_y\text{Ga}_{1-x-y}\text{N}$ ($0 < x < 1$, $0 \leq y \leq 0.2$), and at least a part of said at least one luminescent layer acting as ~~at least~~ a quantum well,

wherein said semiconductor device satisfies at least one of:

a first condition that a threshold mode gain of ~~each of~~ said ~~at least~~ quantum well is more than 12 cm^{-1} , and

a second condition that said semiconductor device has an internal loss " α_i " (cm^{-1}) which satisfies $\alpha_i > 12 \times n - \alpha_m$ (cm^{-1}), where " α_m " is a mirror loss, and "n" is a number of said ~~at least~~ quantum well; and

a third condition that said semiconductor device has a slope efficiency "S" (W/A) which satisfies: $S < 3 \times \{ \alpha_m / (12 \times n) \} \times [\{ (1 - R_1) \sqrt{R_2} \} / \{ (1 - \sqrt{R_1 R_2}) \times (\sqrt{R_1} + \sqrt{R_2}) \}]$, where " R_1 " is a first reflectance of a first cavity facet, from which a light is emitted, " R_2 " is a second reflectance of a second cavity

facet opposite to said first cavity facet, " α_m " is a mirror loss, and "n" is a number of said ~~at least~~ quantum well, and

~~wherein said semiconductor device further satisfies at least one of:~~

~~a fourth condition that~~ a differential gain " dg/dn " of said at least one active layer satisfies $dg/dn \geq 1.0 \times 10^{-20}$ (m²)l[[;]] and

~~a fifth condition that~~ standard deviations of microscopic and macroscopic fluctuations in a band gap energy of said at least luminescent layer are not more than 40 meV; and

wherein said microscopic fluctuation is as measured based on temperature dependence of a photoluminescence lifetime and wherein said microscopic fluctuation is controlled by heat treatment of said semiconductor device at a temperature between 850°C and 1200°C.

72-74. (canceled)

75. (previously presented) The semiconductor device as claimed in claim 71, wherein said semiconductor device has a cavity length "L" of not less than 1000 micrometers, and said first reflectance " R_1 " is not more than 20%, said second reflectance " R_2 " is not less than 80% and less than 100%, and said slope efficiency "S" satisfies $S < 2.1/n$ (W/A).

76. (canceled)

77. (original) The semiconductor device as claimed in claim 71, wherein said semiconductor multi-layer structure comprises a gallium-nitride-based multi-layer structure.

78. (original) The semiconductor device as claimed in claim 77, wherein said gallium-nitride-based multi-layer structure extends over a gallium-nitride-based substrate.

79. (original) The semiconductor device as claimed in claim 77, wherein said gallium-nitride-based multi-layer structure extends over a sapphire substrate.

80. (original) The semiconductor device as claimed in claim 77, wherein said gallium-nitride-based multi-layer structure extends over a substrate having a surface dislocation density of less than 1×10^8 /cm².

81-120. (canceled)

121. (previously presented) The semiconductor device as claimed in claim 71, wherein a standard deviation " Δ_x " in the "microscopic fluctuation" of the indium composition is not more than 0.067.

122. (previously presented) The semiconductor device as claimed in claim 121,

wherein said semiconductor device has a slope efficiency "S" (W/A) which satisfies:

$$S < 3 \times \{\alpha_m / (12 \times n)\} \times [\{ (1 - R_1) \sqrt{R_2} \} / \{ (1 - \sqrt{R_1 R_2}) \times (\sqrt{R_1} + \sqrt{R_2}) \}],$$
 where " R_1 " is a first reflectance of a first cavity facet, from which a light is emitted, " R_2 " is a second

reflectance of a second cavity facet opposite to said first cavity facet, " α_m " is a mirror loss, and "n" is a number of said at least one quantum well.

123. (previously presented) The semiconductor device as claimed in claim 122, wherein said semiconductor device has a cavity length "L" of not less than 1000 micrometers, and said first reflectance " R_1 " is not more than 20%, said second reflectance " R_2 " is not less than 80% and less than 100%, and said slope efficiency "S" satisfies $S < 2.1/n$ (W/A).

124. (previously presented) The semiconductor device as claimed in claim 121, wherein said semiconductor device has an internal loss " α_i " (cm^{-1}) which satisfies $\alpha_i > 12 \times n - \alpha_m$ (cm^{-1}), where " α_m " is a mirror loss, and "n" is a number of said at least one quantum well.

125. (previously presented) The semiconductor device as claimed in claim 121, wherein said semiconductor device has a photo-luminescence peak wavelength distribution of not more than 40 meV in said active layer.

126-128. (canceled)

129. (currently amended) The semiconductor device as claimed in claim 71, wherein the microscopic fluctuations are not ~~[[less]]~~ more than 20 meV.

130. (previously presented) The semiconductor device as claimed in claim 71, wherein a dispersion degree of a thermal

carrier in said active layer is estimated by varying a temperature measurement, so as to determine said microscopic fluctuation.

131. (canceled)